

Our Docket No: 42P10923

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Donghui Lu)	Examiner: Stouffer, Kelly M.
)	
Application No: 10/811,591)	Art Unit: 1792
)	
Filed: March 29, 2004)	Confirmation No: 2696
)	
For: Enhanced Dielectric Layers Using)	
Sequential Deposition)	
_____)	

RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed December 3, 2008, Applicants respectfully request the Examiner to enter the following amendment and to consider the following remark.

CERTIFICATE OF EFS Web

I hereby certify that this correspondence is being submitted electronically via EFS Web on the date shown below to the United States Patent and Trademark Office.

Date of Deposit:	February 10, 2009
Name of Person Mailing Correspondence:	Debbie Casias
Signature	/Debbie Casias/
	/ February 10, 2009 /
	Date